Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	26542	((article or mask or reticle or substrate or wafer) adj4 (position$4 or support$4 or chuck or hold$4)) and clamp$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:45
L2	71	1 and ((circumfere$4 or peripher$4 or outer) near6 (article or substrate or wafer or reticle or mask) near6 (adjust$4 or chang$4 or alter$6 or control$6) near6 (pressure))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:32
L3	1	1 and ((zone or chamber or region or area) near6 (circumferen$4 or outer or peripher$4 or edge) near6 (article or mask or reticle or substrate or wafer) near6 local$4 near6 ((bend$4 or bent) or (thermal adj2 expansion)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:36
L4	1470	1 and ("355"/$.ccls. or "378"/$.ccls. or "310"/$.ccls. or "361"/$.ccls.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:38
L5	584	4 and ((clamp$4 or pressure or vacuum) near7 (zone or chamber or area or region))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:42
L6	55	5 and (((clamp$4 or pressure or vacuum) near7 (zone or chamber or area or region)) near6 (circumferen$4 or peripher$4 or outer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:44
L7	2	6 and (local adj4 (bend$4 or bent or expansion or twist$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:45
L8	1	(((article or mask or reticle or substrate or wafer) adj4 (position$4 or support$4 or chuck or hold$4)) and clamp$4 and (local adj4 bend$4) and (pressure near6 (adjust$4 or control$6 or chang$4))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/19 13:47